



# Kinetic Metallization™

Direct Write of Antenna  
Aperstructures and Electronic  
Interconnects Using Kinetic  
Metallization

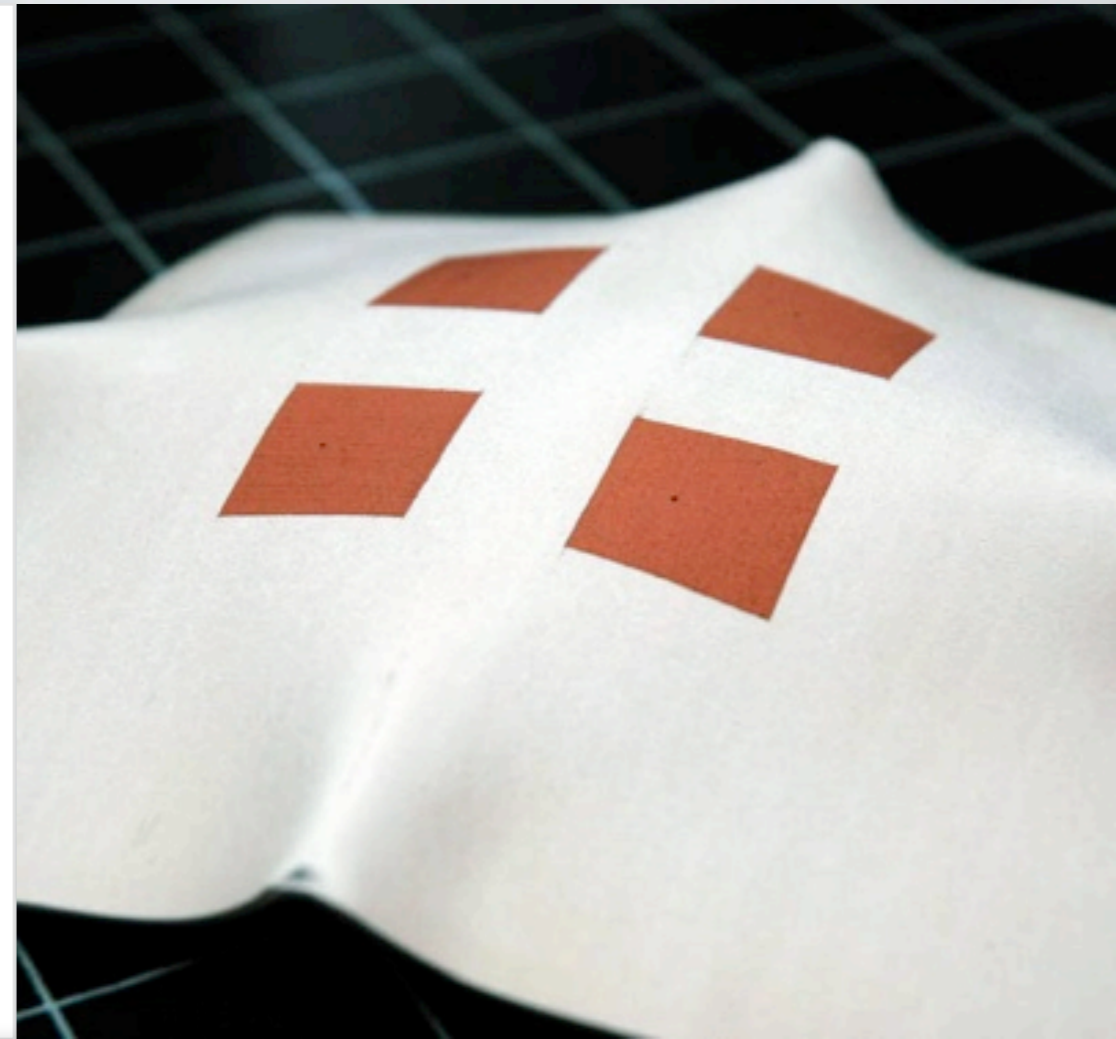
ITSC

5 May 2009

Ralph Tapphorn

# Direct Write of Antenna Elements

- Historical Methods
  - Chemical/mechanical etching
  - Direct write ink-jet printing
  - Laser ablation
- Direct Write - Kinetic Metallization
  - Conductors (Cu, Ag, Ni, Solder)
  - Dielectrics (Ultem, PTFE, Lexan)

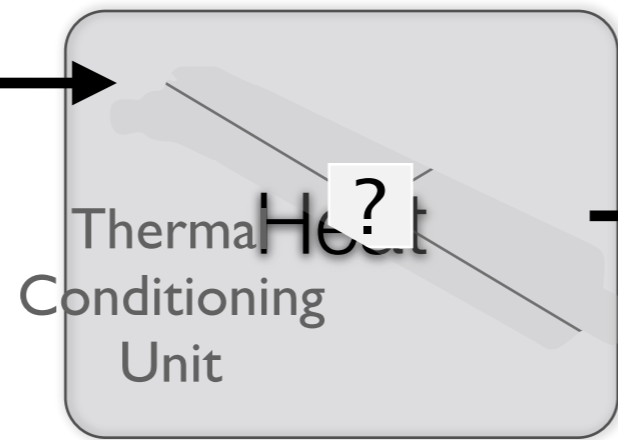
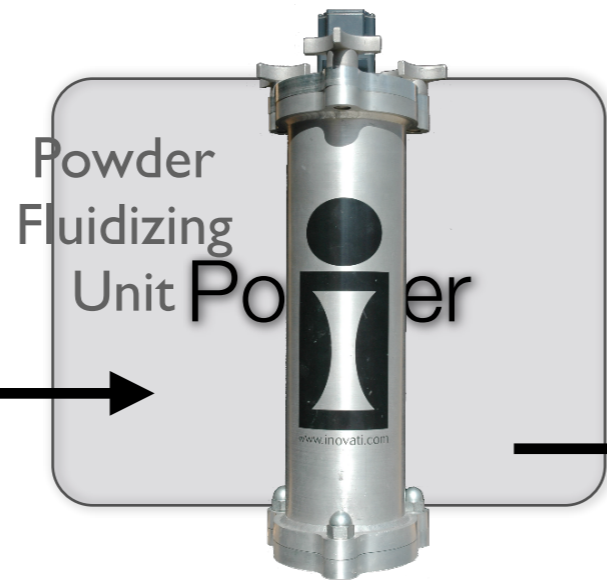
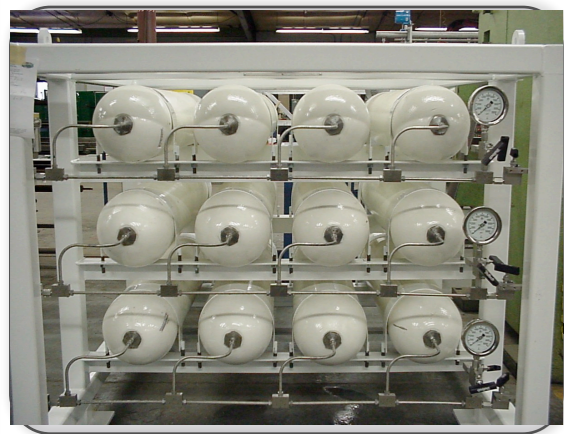


# Introduction to Kinetic Metallization™ (KM)

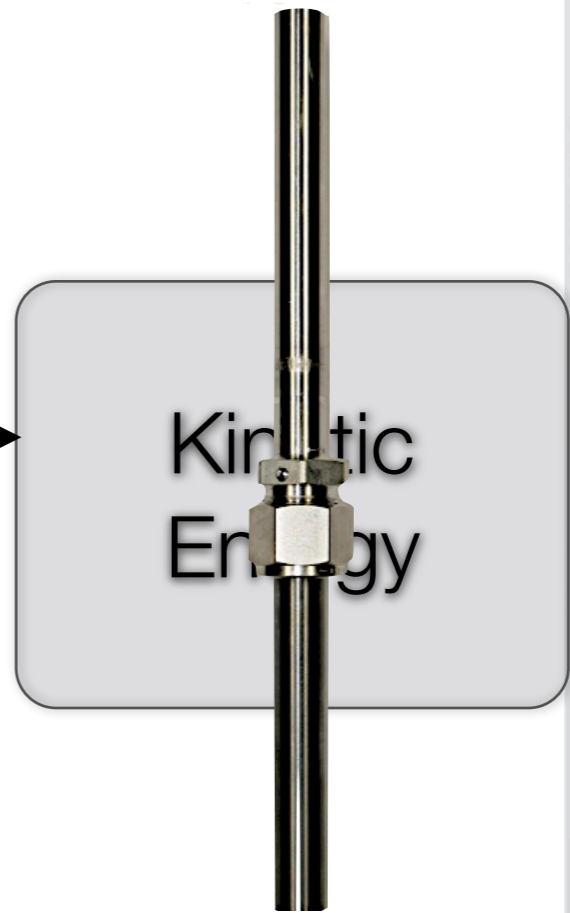
- Metal deposition through particle impact
- low-temperature  $\ll$  melting point
- high particle velocity  $> 500$  m/s
- gas velocity below Mach 1
  - He, 300K, 980 m/s
  - GN2, 300K, 330 m/s



Gas Storage System



Deposition Nozzle







# Kinetic Metallization Systems

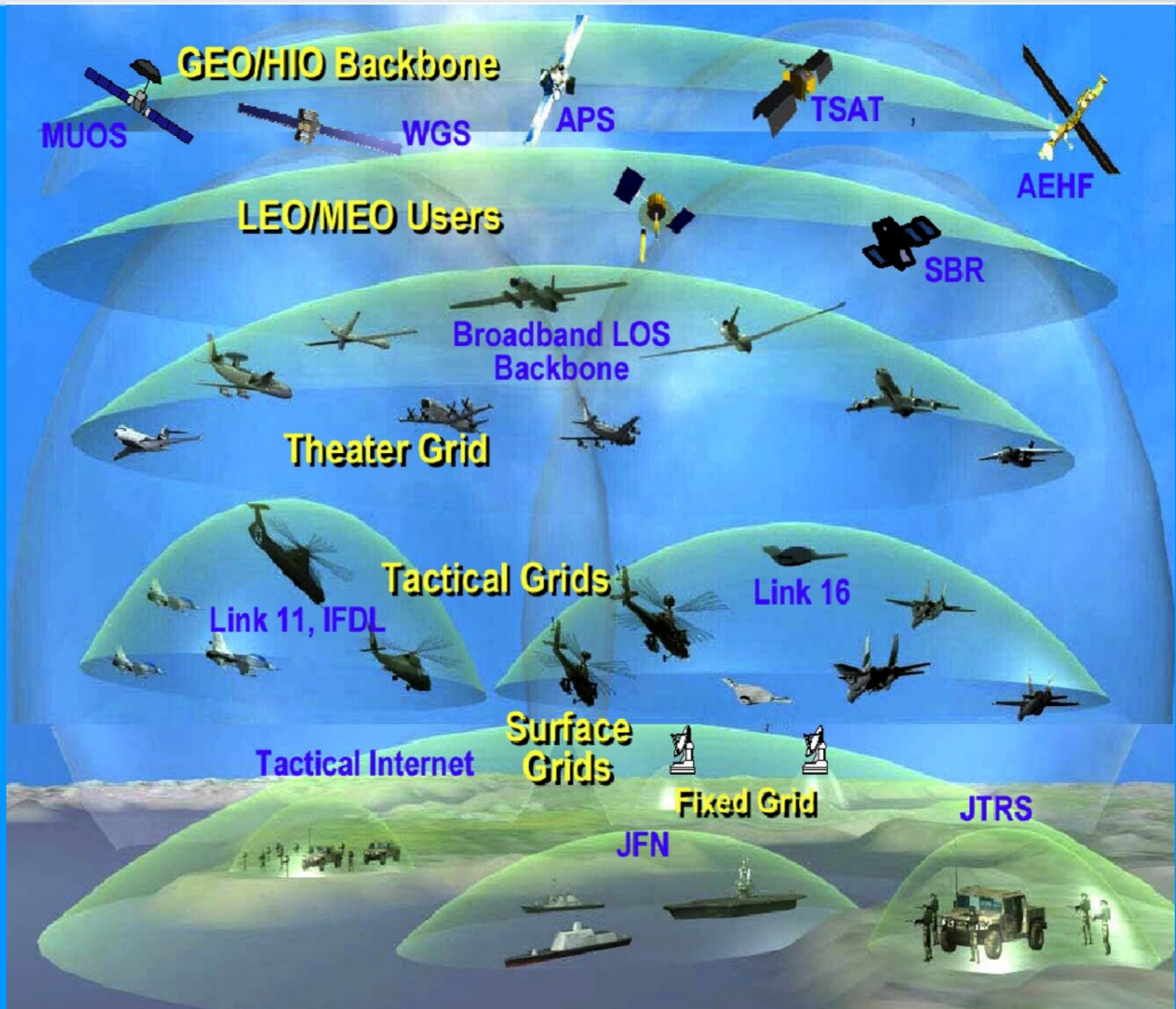
## ■ KM Systems

- Low temperature & Pressure (1 MPa)
- KM-CDS, KM-PCS, & KM-MCS
- Customers Worldwide

## ■ KM Coatings

- Cu, Ag, Ni on polymers & ceramics
- Polymer coatings (Ultem, PTFE)
- Wear resistant coatings (WC-Co)
- Corrosion resistant coatings (Al-Trans®)
- Oxidation resistant coatings (MCrAlY)
- Braze filler coatings (4047-Al)

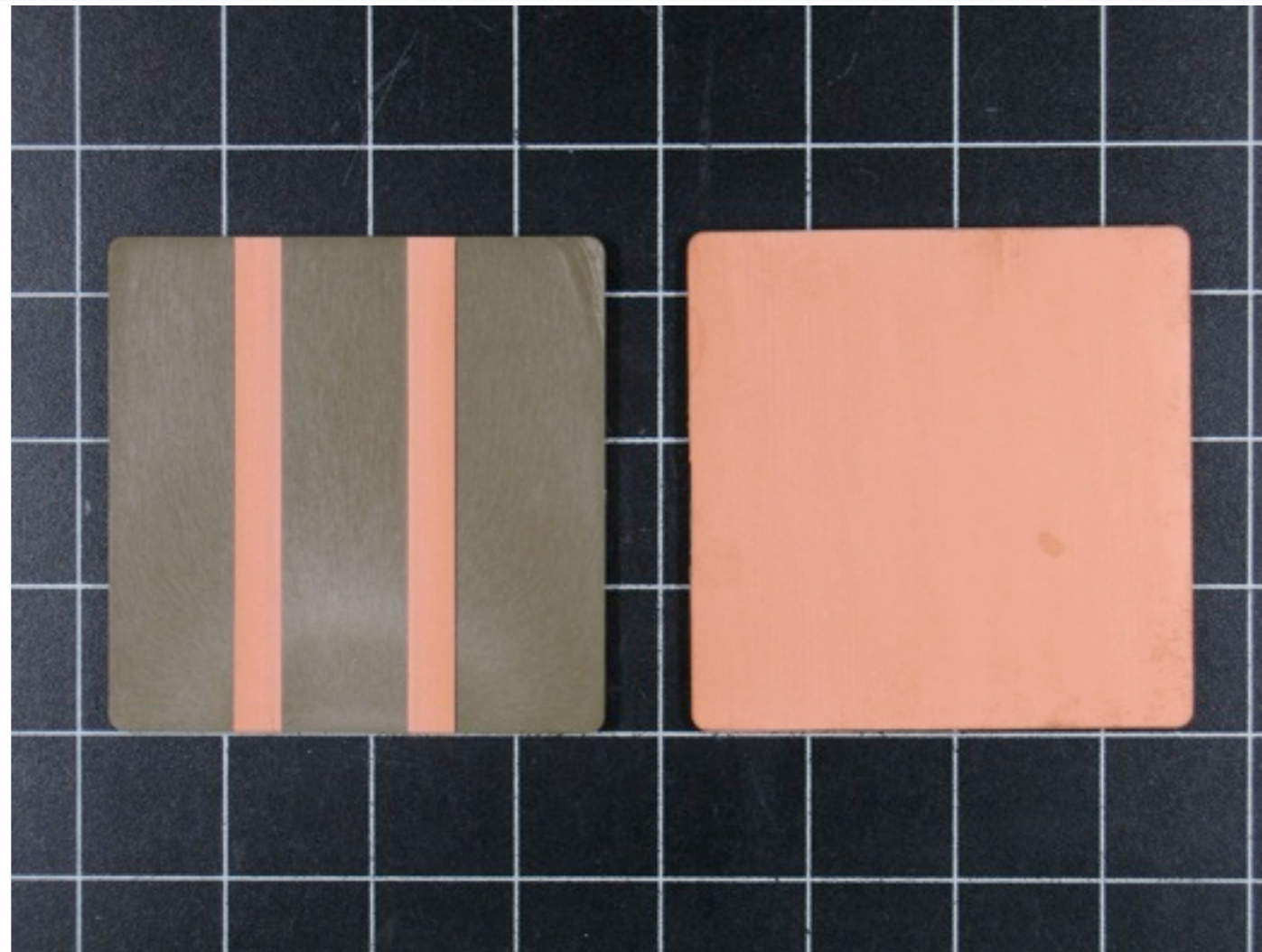




# Military Global SatCom Grid

Microstrip transmission line test coupons with copper coatings on PTFE-Fused Silica composite (RO3003) substrates.



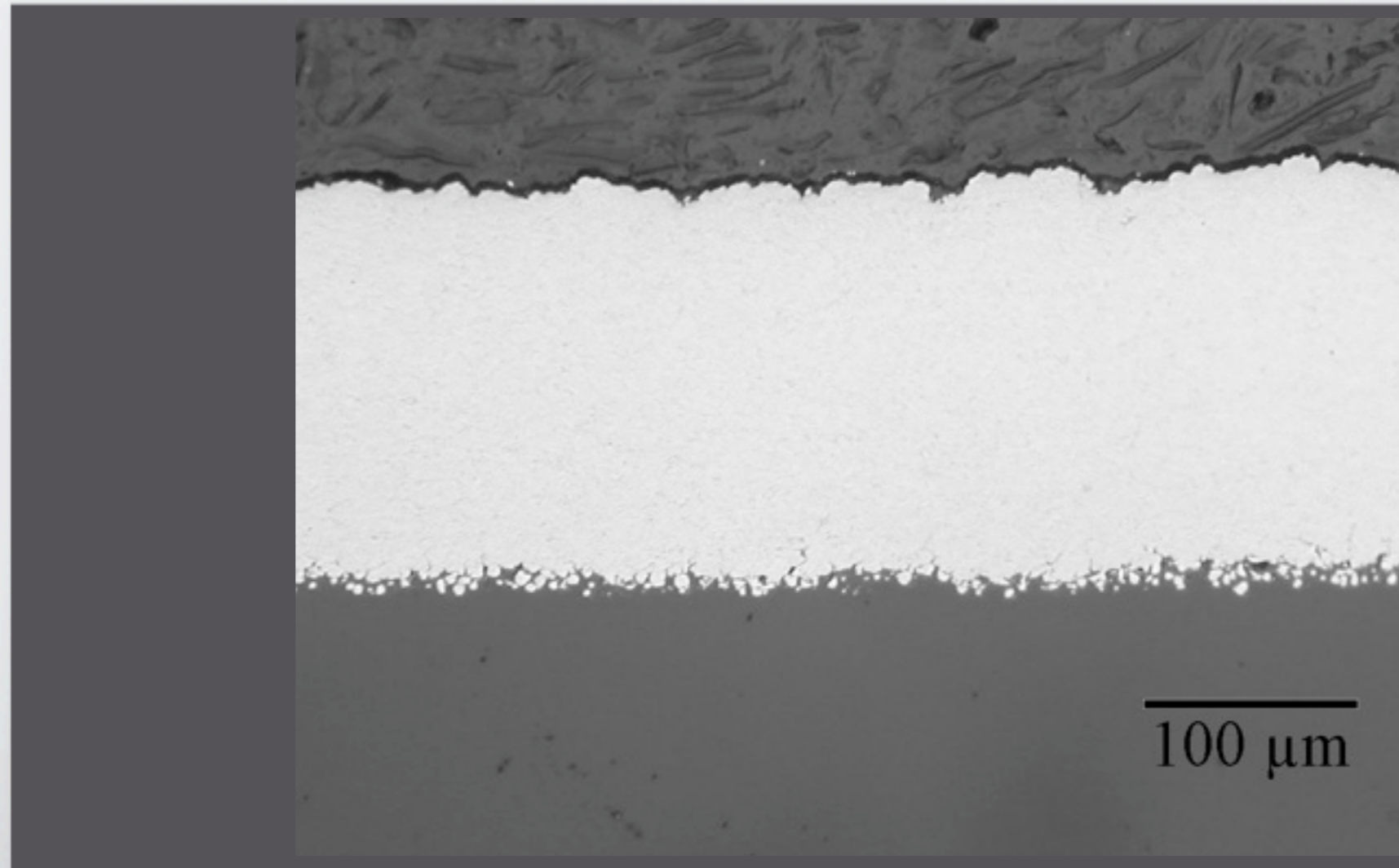


Microstrip Transmission Lines  
KM Cu on Ultem-6202 Plastic





# Micrograph of KM Cu on Ultem Plastic



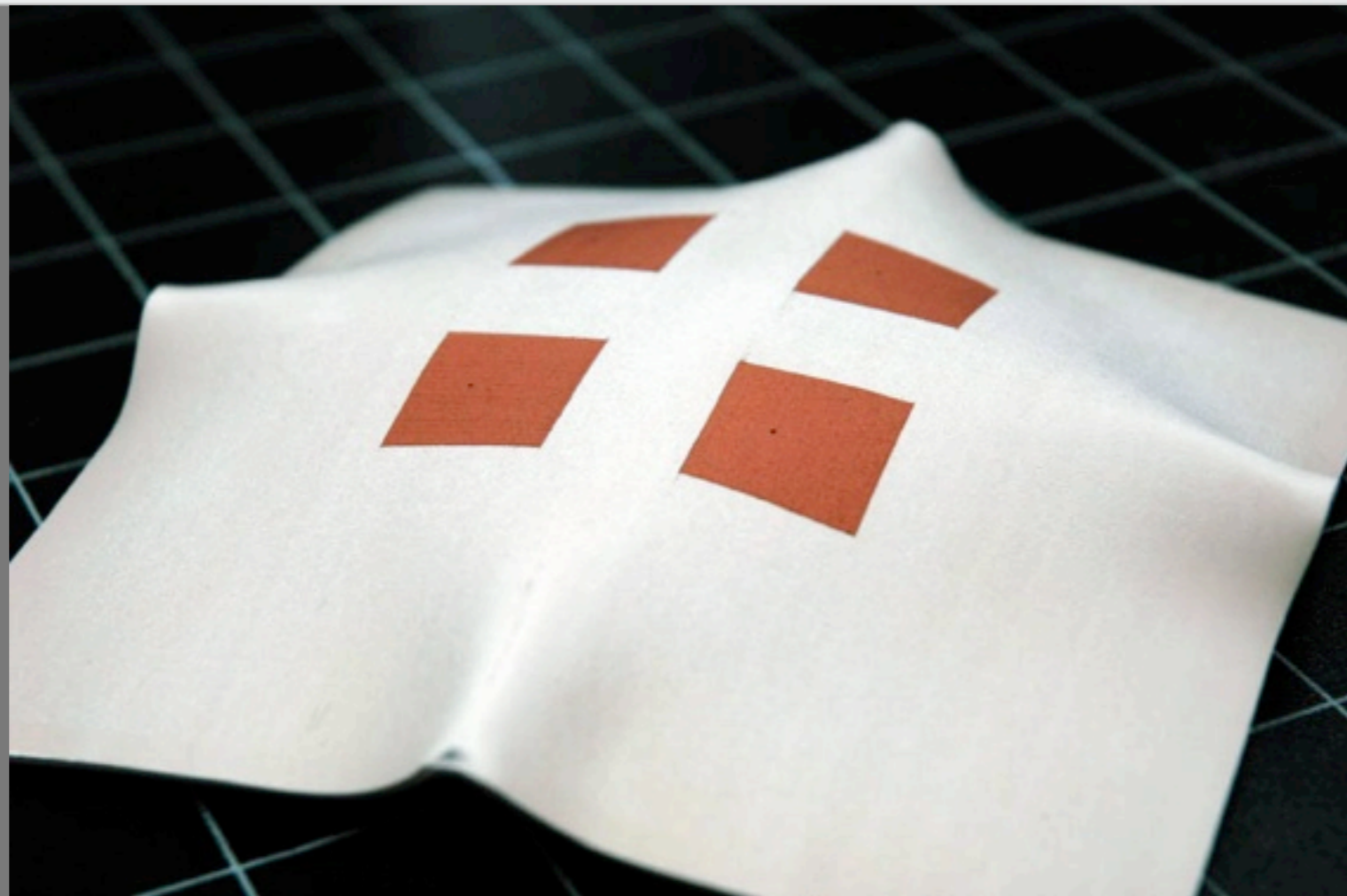


# RF Characteristics

Dielectric Material	Microstrip Coating 30mills	Dielectric Constant	Loss Tangent	Q @ ~1GHz	Dielectric Attenuation Factor (dB/m)	Conductor Attenuation Factor (dB/m)
RO-3003	Cu-Clad	3	0.0013	340	0.16	0.25
RO-3003	KM-Cu	3	0.0013	300	0.15	0.33
Polyfon Ultem	Cu-Clad	3	0.003	170	0.4	0.44
Ultem-1000	KM-Cu	3	0.009	100	1.15	0.23

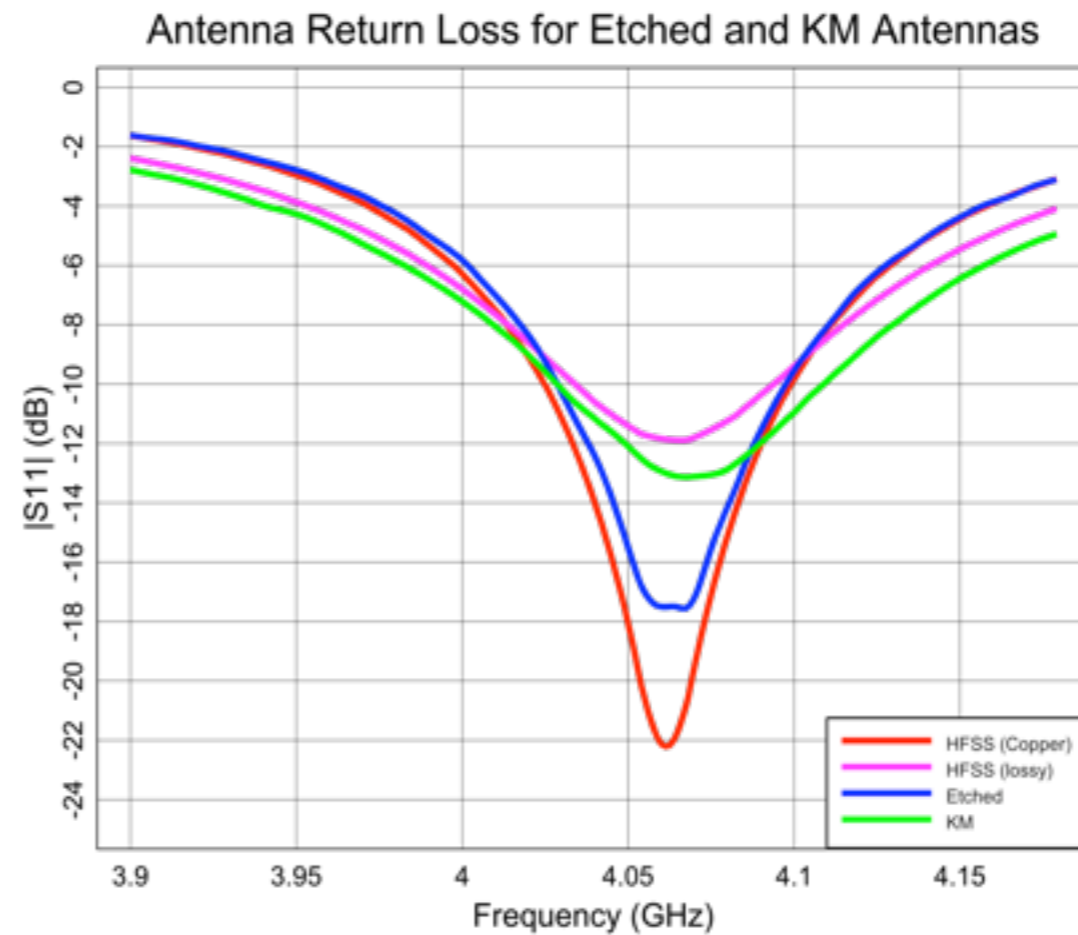


# KM Deposition of Cu on RO-3003 Doubly Curved Surface





# Return Loss Comparison Etched vs. KM Antenna Elements

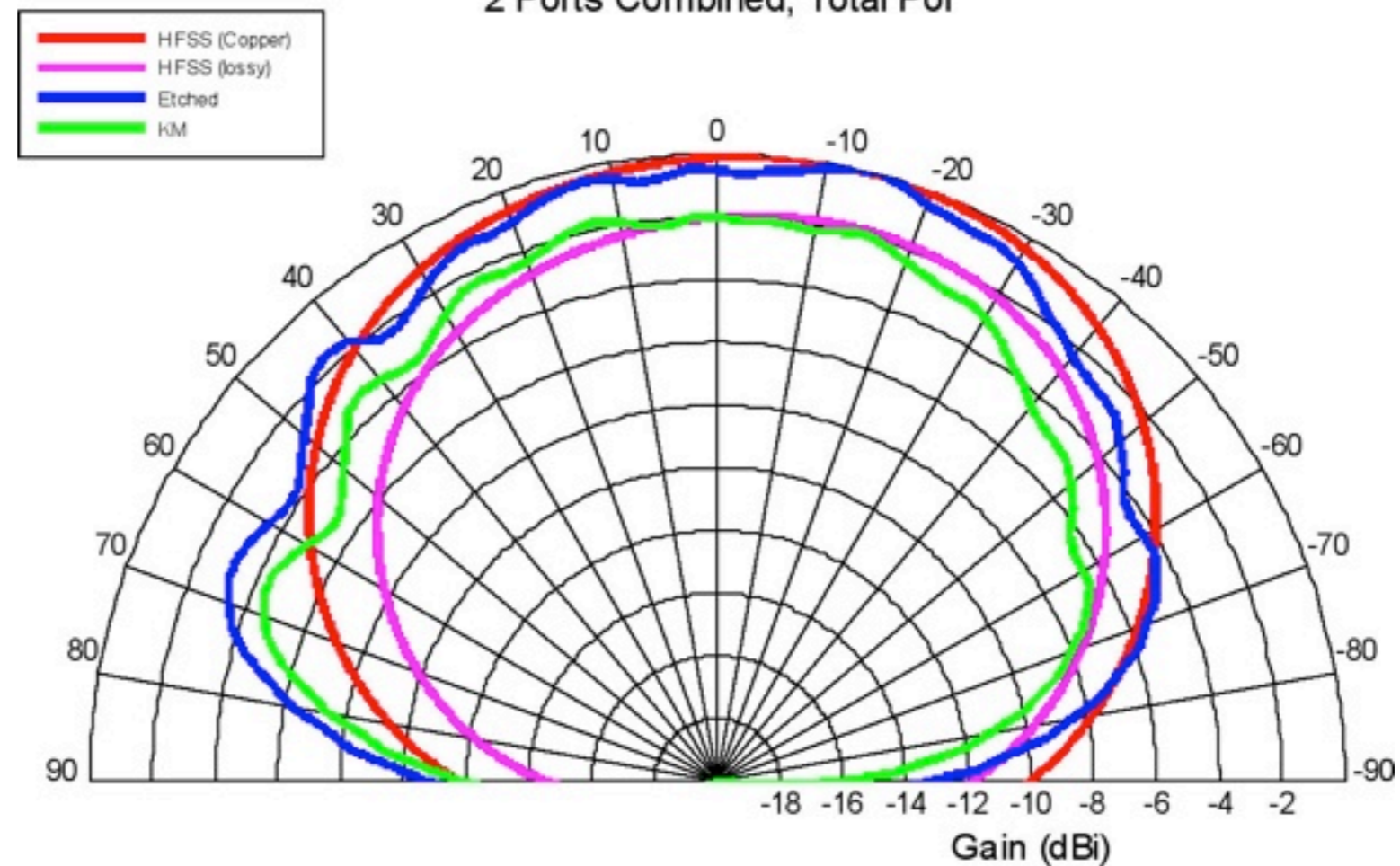


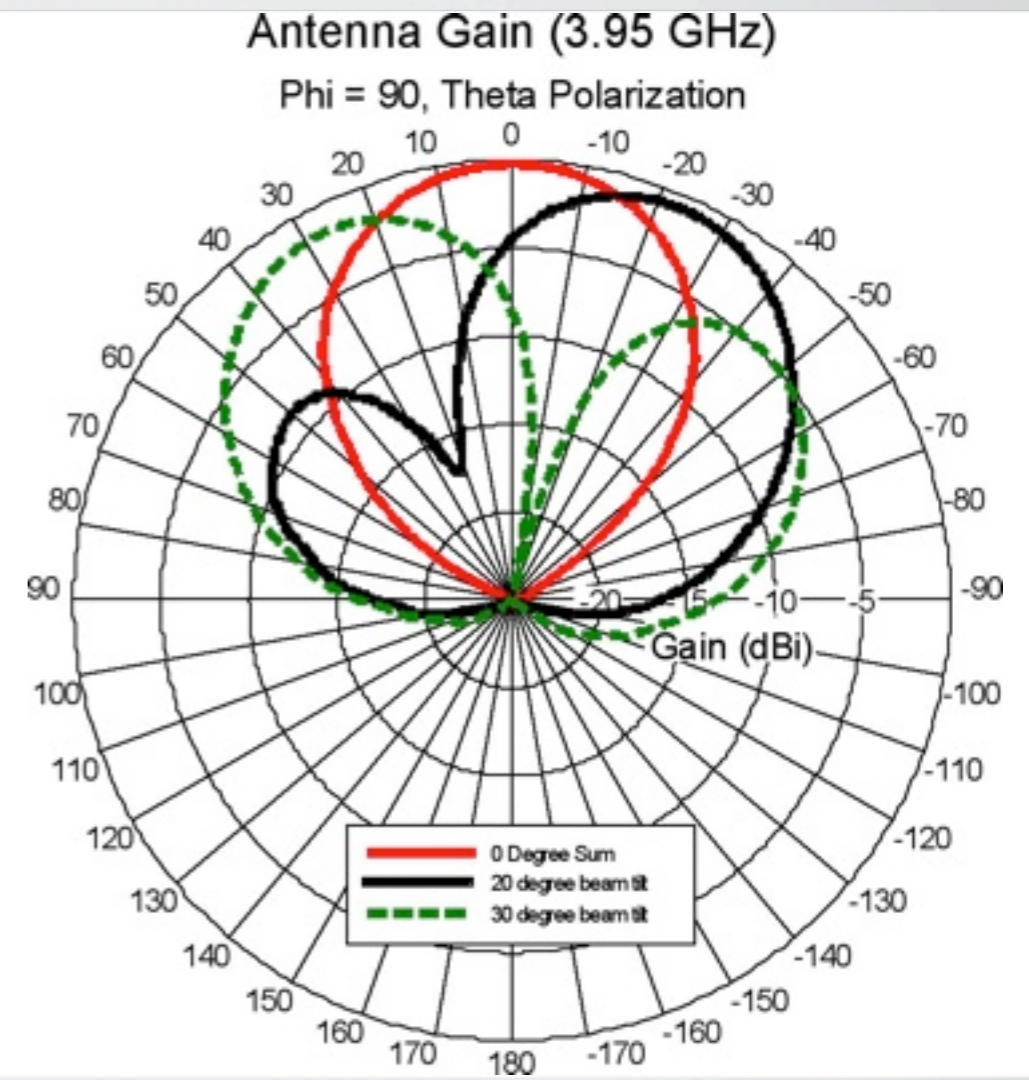
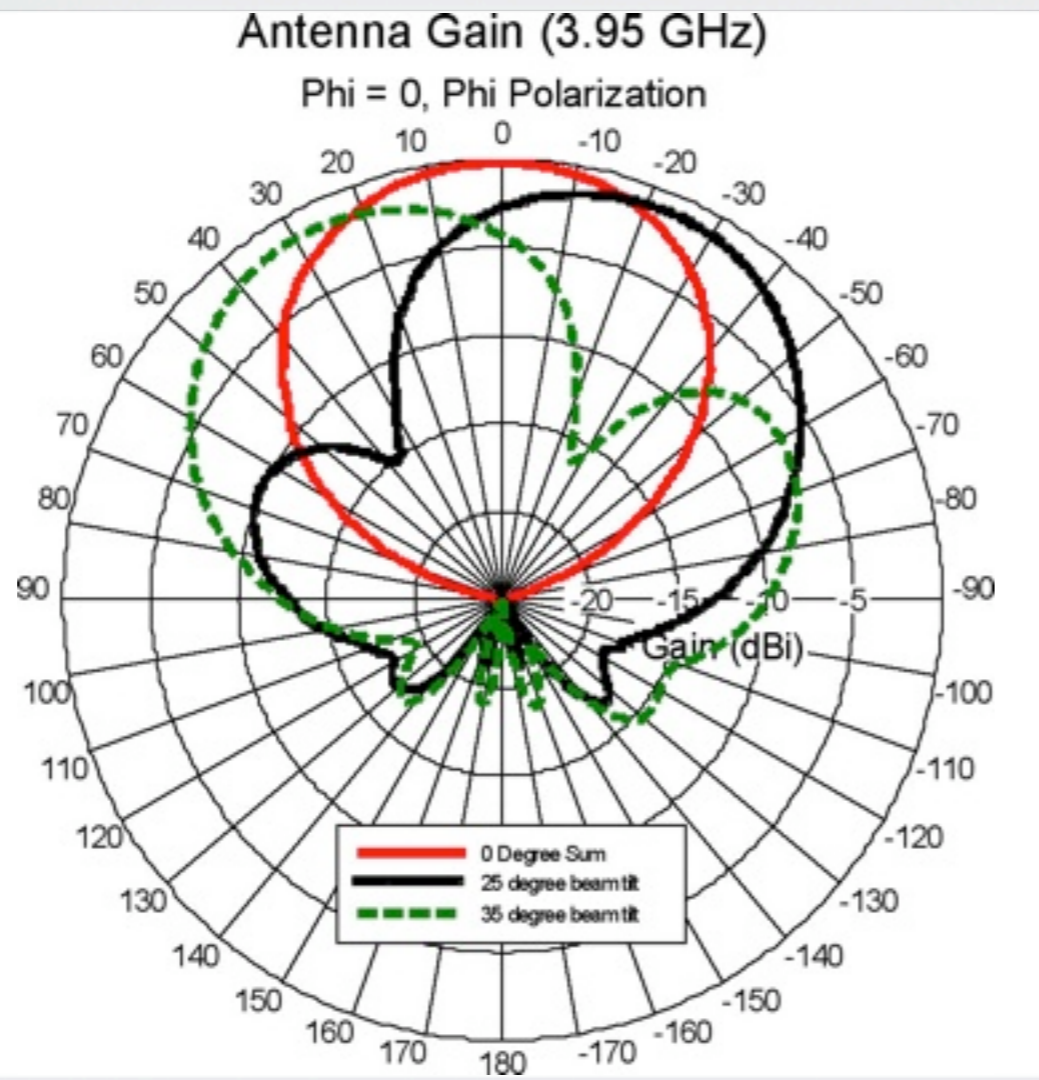


# Antenna Gain

## KM Cu on RO-3003

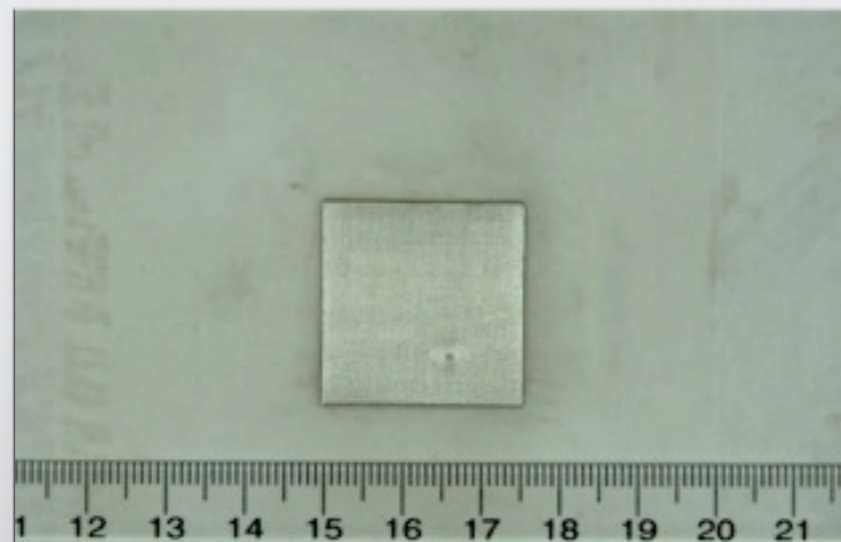
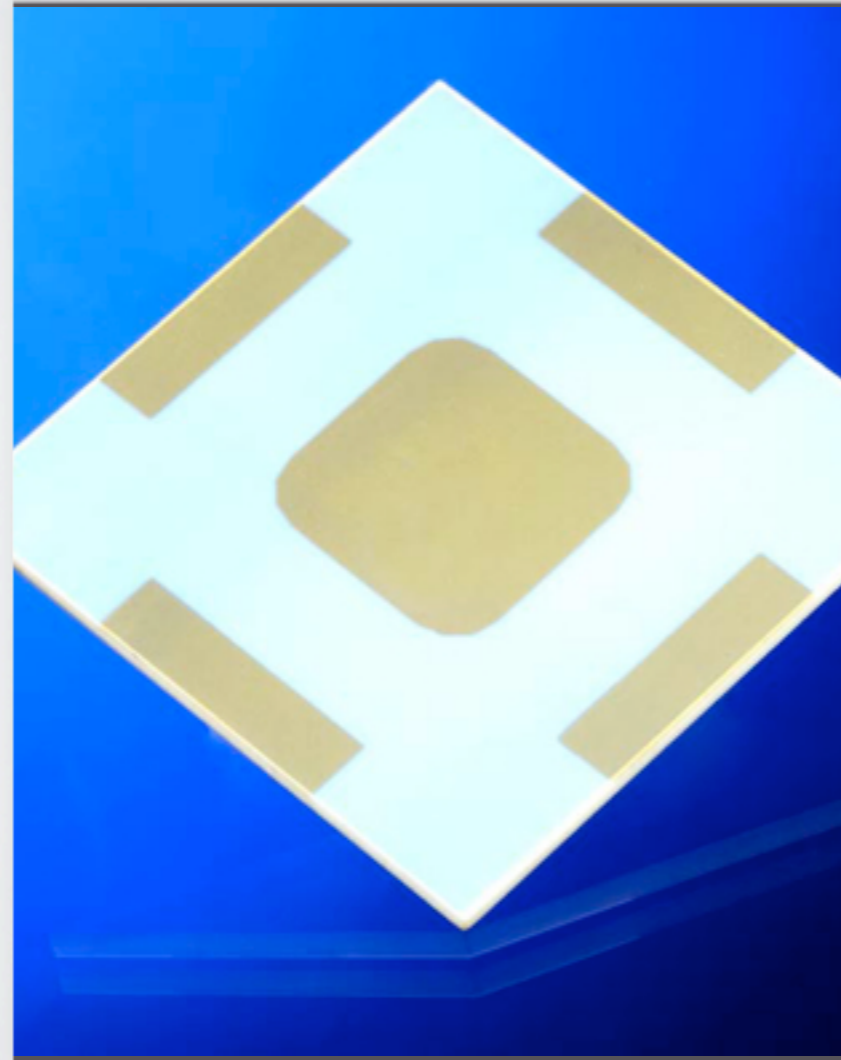
Antenna Gain for Etched and KM Antenna Test Coupons  
2 Ports Combined, Total Pol





# Various Antenna Patterns 4-element Time Delays





# High Temperature Applications

- **RF Antenna for Missile Radomes**
  - Ag, Au, Ni on alumina dielectrics
- **Surface Acoustic Wave Devices**
  - Ag or Au on alumina dielectrics
- **Oxidation Resistant RF Antenna**
  - KM Ni coating on copper conductor
  - Turbine engine sensors/antenna

# Development of KM Dielectric Composites

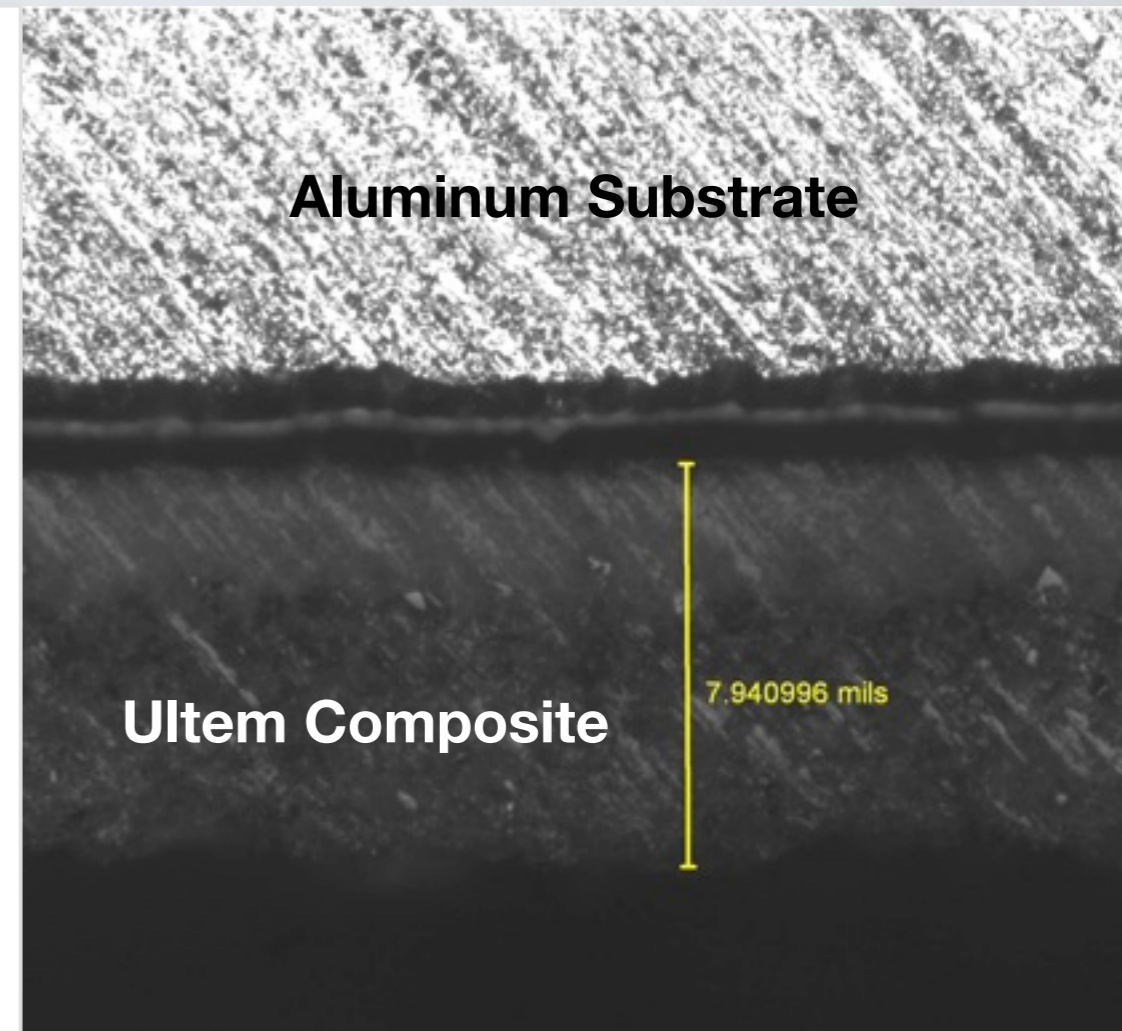
- Polymer Based Composites

- Thermoplastics

- Polyetherimides (Ultem)
    - Fluoroplastics - (PTFE, PVDF)
    - ABS, PVC, Acrylic
    - Polycarbonates (Lexan)

- Ceramic Loading Materials

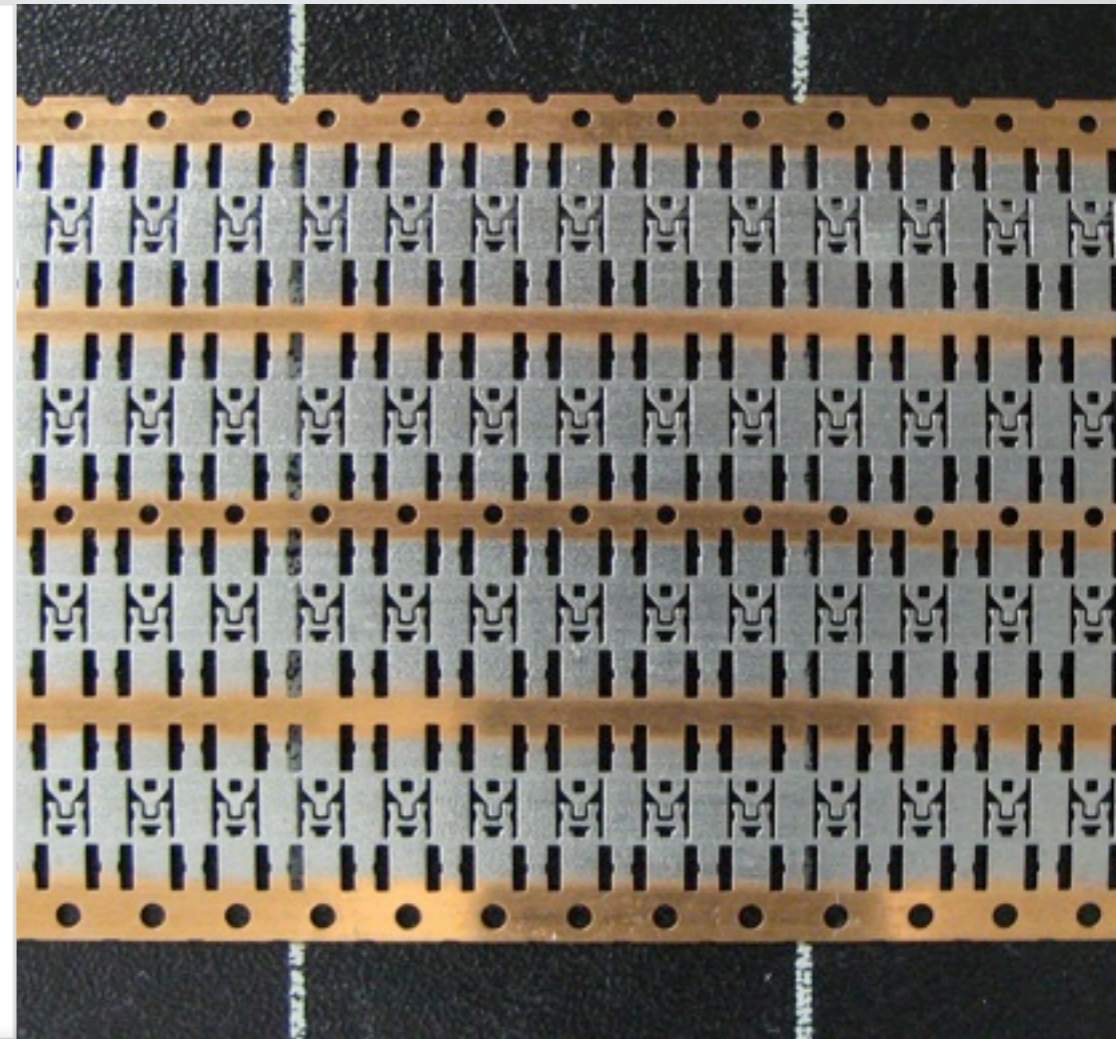
- Alumina, BaTiO<sub>3</sub>, Fused Silica, Quartz, etc.



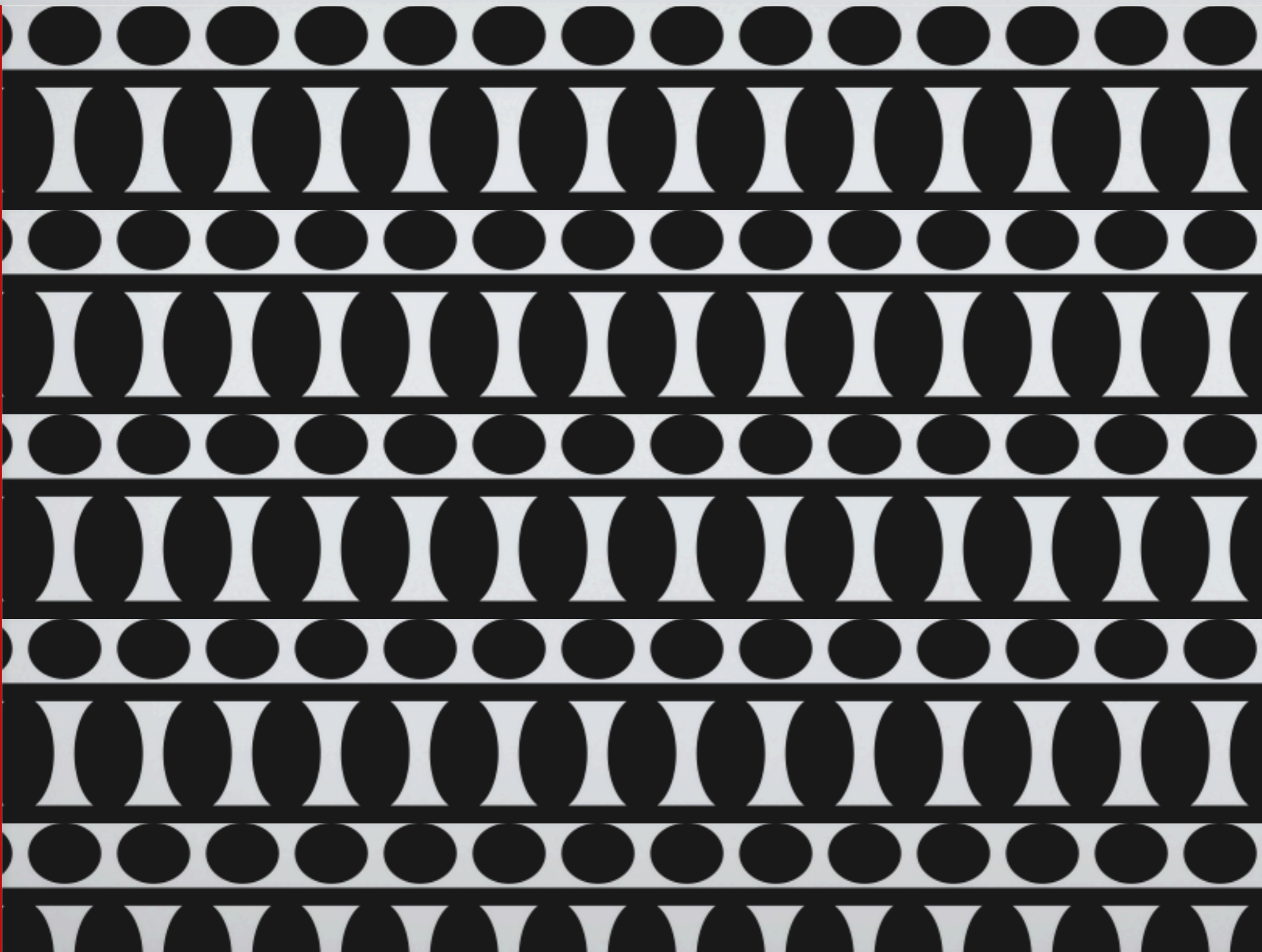


# Electronic Interconnect Applications

- KM Copper Lead Frames
  - Ag films on Cu lead frames
  - Solder films on Cu lead frames
- Solar Panel Interconnects
  - PV grid structure







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information,  
please visit our  
booth #319

